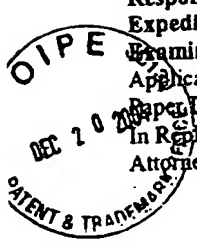


AF IFW



Response Under 37 CFR 1.116
Expedited Procedure
Examining Group 1712
Application No. 10/649,575
Paper Dated: December 14, 2004
In Reply to USPTO Correspondence of October 29, 2004
Attorney Docket No. 1217-031246

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No. : 10/649,575
Applicants : Akira Nakashima et al.
Filed : August 26, 2003
Title : SUBSTRATE COATED WITH SILICA-CONTAINING FILM WITH LOW-DIELECTRIC CONSTANT
Group Art Unit : 1712 Confirmation No. : 5958
Examiner : Margaret G. Moore Customer No. : 28289

OK to enter
mgm
11/7/05

MAIL STOP AF
Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT AFTER FINAL REJECTION

Sir:

In response to the Final Office Action of October 29, 2004, Applicants submit the following amendments and remarks:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 7 of this paper.

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to MAIL STOP AF, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on December 14, 2004.	
_____ Florence P. Trevethan (Name of Person Mailing Paper)	
_____ Signature	12/14/2004 Date